

United States of America

United States Patent and Trademark Office

VCC

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Trademark

Principal Register

HORIBA STEC, Co., Ltd. (JAPAN KABUSHIKI KAISHA (K.K.))
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CLASS 9: Test and measurement machines and instruments, namely, technical measuring, testing and checking apparatus and instruments for measuring, testing and checking the quantity of fluid flow, fluid pressure, fluid concentration, gas concentration of gas and liquids; fluid measurement apparatuses, namely, gas concentration meters; fluid flow controllers, namely, automatic fluid flow control machines for use in controlling a gas concentration; fluid flow meters; fluid flow sensors, namely, electronic sensors for measuring fluid flow; pressure controllers, namely, electronic pressure control systems for machines for use in controlling a gas concentration; pressure meters, namely, pressure meters indicators for use in controlling a gas concentration; pressure sensors; concentration controllers, namely, electronic control systems for machines for regulating gas concentration; concentration meters; concentration sensors, namely, gas sensors for measuring gas concentration; gas concentration controllers, namely, electronic control systems for machines for regulating gas concentration; gas concentration meters; gas concentration sensors, namely, gas sensors for measuring gas concentration; laboratory apparatuses and instruments, namely, electric sensors, for use in measuring fluid flow, fluid pressure, fluid concentrations, gas concentrations; electronic machines, apparatuses and their parts, namely, electronic data processing apparatuses, for use in measuring fluid flow, fluid pressure, fluid concentrations, gas concentrations; computer programs for use in operating equipment for measuring fluid flow, fluid pressure, fluid concentrations, gas concentrations; gas sensors for measuring gas concentration; and automatic gas concentration control machines and instruments, namely, automatic computer-controlled apparatus for measuring concentration of gas for use with machines for manufacturing semiconductors, solar cells, light-emitting diodes, displays, liquid crystal and organic electroluminescent elements



THE MARK CONSISTS OF STANDARD CHARACTERS WITHOUT CLAIM TO ANY PARTICULAR FONT STYLE, SIZE OR COLOR

PRIORITY CLAIMED UNDER SEC. 44(D) ON JAPAN APPLICATION NO. 2017-146607, FILED 11-08-2017, REG. NO. 6076365, DATED 08-31-2018, EXPIRES 08-31-2028

SER. NO. 87-912,646, FILED 05-08-2018

A handwritten signature in cursive script, appearing to read "Andrei Iancu".

Director of the United States
Patent and Trademark Office

REQUIREMENTS TO MAINTAIN YOUR FEDERAL TRADEMARK REGISTRATION

WARNING: YOUR REGISTRATION WILL BE CANCELLED IF YOU DO NOT FILE THE DOCUMENTS BELOW DURING THE SPECIFIED TIME PERIODS.

Requirements in the First Ten Years*

What and When to File:

- **First Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) between the 5th and 6th years after the registration date. See 15 U.S.C. §§1058, 1141k. If the declaration is accepted, the registration will continue in force for the remainder of the ten-year period, calculated from the registration date, unless cancelled by an order of the Commissioner for Trademarks or a federal court.
- **Second Filing Deadline:** You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between the 9th and 10th years after the registration date.* See 15 U.S.C. §1059.

Requirements in Successive Ten-Year Periods*

What and When to File:

- You must file a Declaration of Use (or Excusable Nonuse) and an Application for Renewal between every 9th and 10th-year period, calculated from the registration date.*

Grace Period Filings*

The above documents will be accepted as timely if filed within six months after the deadlines listed above with the payment of an additional fee.

***ATTENTION MADRID PROTOCOL REGISTRANTS:** The holder of an international registration with an extension of protection to the United States under the Madrid Protocol must timely file the Declarations of Use (or Excusable Nonuse) referenced above directly with the United States Patent and Trademark Office (USPTO). The time periods for filing are based on the U.S. registration date (not the international registration date). The deadlines and grace periods for the Declarations of Use (or Excusable Nonuse) are identical to those for nationally issued registrations. See 15 U.S.C. §§1058, 1141k. However, owners of international registrations do not file renewal applications at the USPTO. Instead, the holder must file a renewal of the underlying international registration at the International Bureau of the World Intellectual Property Organization, under Article 7 of the Madrid Protocol, before the expiration of each ten-year term of protection, calculated from the date of the international registration. See 15 U.S.C. §1141j. For more information and renewal forms for the international registration, see <http://www.wipo.int/madrid/en/>.

NOTE: Fees and requirements for maintaining registrations are subject to change. Please check the USPTO website for further information. With the exception of renewal applications for registered extensions of protection, you can file the registration maintenance documents referenced above online at <http://www.uspto.gov>.

NOTE: A courtesy e-mail reminder of USPTO maintenance filing deadlines will be sent to trademark owners/holders who authorize e-mail communication and maintain a current e-mail address with the USPTO. To ensure that e-mail is authorized and your address is current, please use the Trademark Electronic Application System (TEAS) Correspondence Address and Change of Owner Address Forms available at <http://www.uspto.gov>.